

TECHNICAL SPECIFICATION



Piezoelectric, dielectric and electrostatic devices and associated materials for frequency control, selection and detection – Glossary –
Part 4-4: Piezoelectric materials – ~~Materials~~ Single crystal wafers for surface acoustic wave (SAW) devices



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INTERNATIONAL ELECTROTECHNICAL COMMISSION

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Part 4-4: Piezoelectric materials –~~Materials~~ Single crystal wafers for surface acoustic wave (SAW) devices

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- the required support cannot be obtained for the publication of an International Standard, despite repeated efforts, or
- the subject is still under technical development or where, for any other reason, there is the future but no immediate possibility of an agreement on an International Standard.

Technical specifications are subject to review within three years of publication to decide whether they can be transformed into International Standards.

IEC TS 61944-4-4, which is a technical specification, has been prepared by IEC technical committee 49: Piezoelectric, dielectric and electrostatic devices and associated materials for frequency control, selection and detection.

This third edition of IEC 61994-4-4 cancels and replaces the second edition published in 2010. This edition constitutes a technical revision.

This edition includes the following significant technical changes with respect to the previous edition:

- a) the new terms and definitions given in IEC 62276:2016 have been taken into account;
- b) the general title has been changed according to the change in the title of TC 49 in 2009.
- c) the part title has been changed according to the title of IEC 62276:2016.

The text of this technical specification is based on the following documents:

Enquiry draft	Report on voting
49/1283/DTS	49/1287/RVC

Full information on the voting for the approval of this technical specification can be found in the report on voting indicated in the above table.

This document has been drafted in accordance with the ISO/IEC Directives, Part 2.

A list of all parts in the IEC 61994 series, published under the general title *Piezoelectric, dielectric and electrostatic devices and associated materials for frequency control, selection and detection – Glossary*, can be found on the IEC website.

Future standards in this series will carry the new general title as cited above. Titles of existing standards in this series will be updated at the time of the next edition.

The committee has decided that the contents of this document will remain unchanged until the stability date indicated on the IEC website under "<http://webstore.iec.ch>" in the data related to the specific document. At this date, the document will be

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PIEZOELECTRIC, DIELECTRIC AND ELECTROSTATIC DEVICES AND ASSOCIATED MATERIALS FOR FREQUENCY CONTROL, SELECTION AND DETECTION – GLOSSARY –

Part 4-4: Piezoelectric materials – ~~Materials~~ Single crystal wafers for surface acoustic wave (SAW) devices

1 Scope

This part of IEC 61994 ~~specifies~~ gives the terms and definition for single crystal wafers ~~applied~~ for surface acoustic wave (SAW) devices representing the state of the art, ~~which are intended for use in the standards and documents of IEC technical committee 49.~~

2 Normative references

The following documents are referred to in the text in such a way that some or all of their content constitutes requirements of this document. For dated references, only the edition cited applies. For undated references, the latest edition of the referenced document (including any amendments) applies.

~~ISO 4287, Geometrical Product Specifications (GPS) – Surface texture: Profile method – Terms, definitions and surface texture parameters~~

There are no normative references in this document.

3 Terms and definitions

For the purposes of this document, the following terms and definitions apply.

ISO and IEC maintain terminological databases for use in standardization at the following addresses:

- IEC Electropedia: available at <http://www.electropedia.org/>
- ISO Online browsing platform: available at <http://www.iso.org/obp>

~~3.1~~ ~~acceptable quality level~~

~~AQL~~

~~AQL is the maximum percent defective (or the maximum number of defects per hundred units) that, for purposes of sampling inspections, can be considered satisfactory as a process average~~

~~[IEC 60410:1973, 4.2]~~

3.1 Single crystals for SAW wafer

3.1.1

as-grown synthetic quartz crystal

right-handed or left-handed single crystal quartz grown hydrothermally. ~~“As-grown” refers to the state of processing and indicates a state prior to mechanical fabrication~~

[SOURCE: ~~IEC 61994-4-1:2007, 3.4~~ IEC 62276:2016, 3.1.1, modified – Notes 1 and 2 to entry have been removed.]

3.1.2

lanthanum gallium silicate

LGS

single crystals described by the chemical formula to $\text{La}_3\text{Ga}_5\text{SiO}_{14}$, grown by Czochralski (crystal pulling from melt) or other growing methods

[SOURCE: IEC 62276:2005 2016, 3.1.5]

3.1.3

lithium niobate

LN

single crystals approximately described by chemical formula LiNbO_3 , grown by Czochralski (crystal pulling from melt) or other growing methods

[SOURCE: IEC 62276:2005 2016, 3.1.2]

3.1.4

lithium tantalate

LT

single crystals approximately described by chemical formula LiTaO_3 , grown by Czochralski (crystal pulling from melt) or other growing methods

[SOURCE: IEC 62276:2005 2016, 3.1.3]

3.1.5

lithium tetraborate

LBO

single crystals described by the chemical formula to $\text{Li}_2\text{B}_4\text{O}_7$, grown by Czochralski (crystal pulling from melt), vertical Bridgman, or other growing methods

[SOURCE: IEC 62276:2005 2016, 3.1.4]

3.2 Terms and definitions related to LN and LT crystals

3.2.1

curie temperature

T_c

phase transition temperature between ferroelectric and paraelectric phases measured by differential thermal analysis (DTA) or dielectric measurement

[SOURCE: IEC 62276:2005 2016, ~~3.3.1~~ 3.2.1]

3.2.2

polarization ~~(or poling)~~ process

electrical process used to establish a single domain crystal

[SOURCE: IEC 62276:2005 2016, ~~3.3.3~~ 3.2.3]

3.2.3

reduction process

REDOX reaction to increase conductivity to reduce the harmful effects of pyroelectricity

[SOURCE: IEC 62276:2005 2016, ~~3.3.4~~ 3.2.4]

3.2.4

reduced LN

LN treated with a reduction process, ~~sometimes referred to as “black LN”~~

[SOURCE: IEC 62276:2005 2016, ~~3.3.4.1~~ 3.2.5, modified – Note 1 to entry has been removed.]

3.2.5

reduced LT

LT treated with a reduction process, ~~sometimes referred to as “black LT”~~

[SOURCE: IEC 62276:2005 2016, ~~3.3.4.2~~ 3.2.6, modified – Note 1 to entry has been removed.]

3.2.6

single domain

ferroelectric crystal with uniform electrical polarization throughout (for LN and LT)

[SOURCE: IEC 62276:2005 2016, ~~3.3.2~~ 3.2.2]

3.3 Terms and definitions related to all crystals

3.3.1

congruent composition

chemical composition of a single crystal in a thermodynamic equilibrium with a molten solution of the same composition during the growth process

[SOURCE: IEC 62276:2005 2016, ~~3.4.2~~ 3.3.2]

3.3.2

lattice constant

length of ~~one~~ unit cell along a major crystallographic axis measured by X-ray using the Bond method

[SOURCE: IEC 62276:2005 2016, ~~3.4.1~~ 3.3.1]

3.3.3

twin

~~crystallographic defect occurring in a single crystal~~

~~NOTE The twin is separated from the rest of the material by a boundary, generally aligned along a crystal plane. The lattices on either side of the boundary are crystallographic mirror images of one another.~~

two or more same single crystals which are combined together by the law of symmetrical plane or axis

[SOURCE: IEC 62276:2005 2016, ~~3.4.3~~ 3.3.3, modified – Notes 1 and 2 to entry have been removed.]

3.4 Flatness

3.4.1

fixed quality area

FQA

central area of a wafer surface, defined by a nominal edge exclusion, X, over which the specified values of a parameter apply

[SOURCE: IEC 62276:2005 2016, ~~3.7.1~~ 3.4.1, modified – Note 1 to entry has been removed.]

3.4.2 local thickness variation LTV

variation determined by a measurement of a matrix of sites with defined edge dimensions (~~e.g.~~
~~5 mm × 5 mm~~).

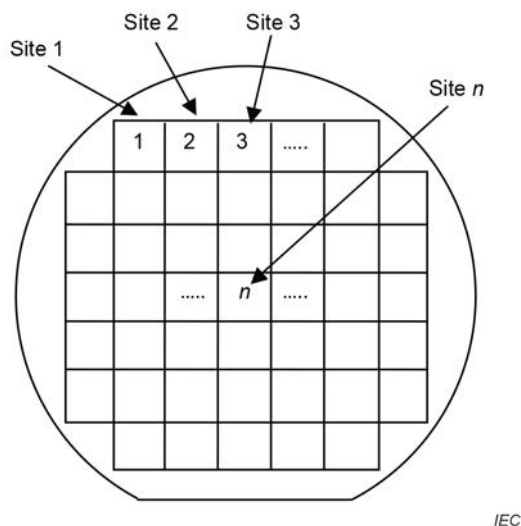


Figure 1 – Example of site distribution for LTV measurement
All sites have their centres within the FQA

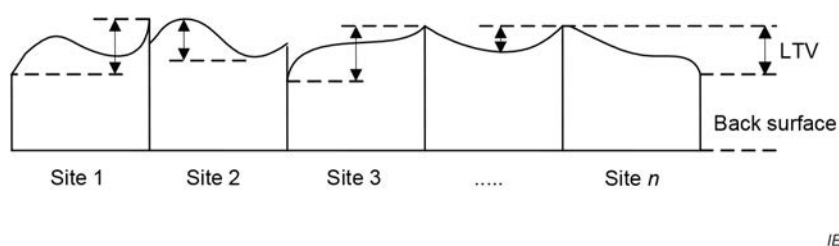


Figure 2 – LTV is a positive number and is measured at value of each site

Note 1 to entry: All sites have their centres within the FQA.

Note 2 to entry: Measurement is performed on a clamped wafer with the reference plane as defined in ~~3.30a~~ 3.4.5 a). A site map example is shown in Figure 1. The value is always a positive number and is defined for each site as the difference between the highest and lowest points within each site, as shown in Figure 2. For a wafer to meet an LTV specification, all sites ~~must~~ shall have LTV values less than the specified value.

[SOURCE: IEC 62276: ~~2005~~ 2016, ~~3.7.8~~ 3.4.8]

3.4.3 focal plane deviation FPD

deviation measured relative to the 3-point reference plane

Note 1 to entry: The 3-point reference plane is defined in ~~3.30b~~ 3.4.5 b).

Note 2 to entry: The value obtained indicates the maximum distance between a point on the wafer surface (within the FQA) and the focal plane. If that point is above the reference, the FPD is positive. If that point is below the reference plane, the FPD is negative.

[SOURCE: IEC 62276: ~~2005~~ 2016, ~~3.7.10~~ 3.4.10]